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In the claims:

Please cancel claims 1-5 and 13-17.

Please add the following claim:

23. The method of claim ~~18~~ wherein the layer of chromium is deposited to a thickness between about 500 and 2,800 Angstroms.

Please amend the following claims:

17. A liquid crystal display having reduced common electrode resistance comprising:

two polarizers;

upper and lower substrates, each having upper and lower surfaces, between said polarizers;

an array of sub-pixel-sized color filters, separated one from another by a separation area, on the upper surface of said lower substrate;

an overcoat layer over said array of color filters and said upper surface of said lower substrate;

a black matrix on said overcoat layer;

a layer of transparent, electrically conductive, material on

insert C' said overcoat layer and embedding said black matrix; C' A

means, on the lower surface of said upper substrate, for

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applying an electric field normal to any one of said color filters; and

a layer of liquid crystal confined between said upper and lower substrates.

B3 18. A method for making a black matrix in a liquid crystal display comprising:

(a) providing a transparent insulating substrate having an upper surface;

(b) coating said upper surface with a layer of a photosensitive resin in which a colored pigment has been dispersed;

(c) selectively exposing sub-pixel-sized regions of said photosensitive resin, there being a separation area between said regions, to ultraviolet light and then removing all unexposed regions of said resin layer;

(d) coating said upper surface, including any exposed resin, with a layer of photosensitive resin in which has been dispersed a pigment of a color different from any already present on said upper surface, and then repeating step (c);

(e) repeating step (d) one or more times;

(f) depositing an overcoat layer;

(g) depositing a layer of chromium;

(h) selectively etching said layer of chromium so as to

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leave said pixel-sized regions uncovered and said separation area covered; and

(i) depositing a transparent, electrically conductive, layer ^{C²} that embeds the etched chromium

by 8.20. The method of claim ⁶18 wherein said layer of transparent, electrically conductive material comprises indium tin oxide deposited to a thickness between about [500] 1,000 and about 3,000 Angstroms.

REMARKS

Examiner Duong is thanked for his new insights and Office Action. We wish to comment on his most recent remarks, and the new reference that he has cited, as follows:

Examiner's rejection of claims 1-4 based on 35 U.S.C. 102 (EP 0509827) is accepted. These claims have now been cancelled.

Examiner's rejection of claim 5 based on 35 U.S.C. 103 (EP 0509827 in view of Yamazaki) is accepted. This claim has now been cancelled.

Examiner's rejection of claims 13-17 based on 35 U.S.C. 103

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